



## Recent Technologies on CO<sub>2</sub> Capture and (Photo) Electrochemical Utilization

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submissions:

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### Message from the Guest Editors

This Special Issue aims to compile medium-sized review papers or original research articles showcasing pertinent and recent developments or achievements in CO<sub>2</sub> capture and (photo)electrochemical utilization. Topics of interest include, but are not limited to, the utilization and development of both commercial and novel processes for CO<sub>2</sub> capture (such as chemical absorption, pressure swing adsorption, and membrane technologies, among others) and (photo)electrochemical utilization applications, alongside life-cycle assessment and technoeconomic analysis of these processes. As such, we welcome both original research papers and review articles.

We are looking forward to receiving your contributions.





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## Message from the Editor-in-Chief

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